## E lectric readout of m agnetization dynam ics in a ferrom agnet-sem iconductor system

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## Abstract

We apply an analysis of time-dependent spin-polarized current in a sem iconductor channel at room temperature to establish how the magnetization con guration and dynamics of three ferromagnetic term in als, two of them biased and third connected to a capacitor, a ect the currents and voltages. In a steady state, the voltage on the capacitor is related to spin accumulation in the channel. When the magnetization of one of the term in als is rotated, a transient current is triggered. This electrode or for dynamical readout of the alignment of two magnetization contacts.

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Integration of non-volatile magnetic memory into semiconductor electronics is one of the goals of spintronics. Current magnetic random -access memory (MRAM) implementations are based on all-metallic systems, [1] maintaining a physical separation between the memory and the logic parts in computer architectures. Several theoretical proposals of spin transistors involving semiconductors have been put forth, [2, 3, 4, 5, 6] but the experimental veri cation is yet to be made. Recently, we have proposed a system consisting of three ferromagnetic metal contacts on top of a planar semiconductor channel, [7] in which the exibility provided by a third terminal allows to directly express the magnitude of spin accumulation in the semiconductor channel by electrical means. This system relies on currently available parameters of metal/semiconductor spin injecting structures involving Fe and GaAs. [8, 9, 10, 11]

In this Letter, we explore the possibility of a dynamical read-out scheme in a threeterm in alsystem in Fig. 1 based on a time-dependent analysis of the lateral spin di usion under the ferrom agnetic contact. The lateral scale of the planar structure is set by the spin di usion length  $L_{sc}$ , about 1 m in GaAs at room temperature, the distance within which the electron spin polarization is preserved. The ferrom agnetic term in als have collinear m agnetizations. Bias is applied between the left (L) and the middle (M) contacts. The right contact (R) is connected to a capacitor C which blocks the current in steady state. The voltage on the capacitor depends on the alignment of L and M magnetizations as well as on the spin selective properties of the R term inal. This is known as the non-local spin-valve e ect [12, 13, 14]. In the following, we x the M term in almagnetization, which can be realized by using an antiferrom egnetic capping layer. [15] To change the magnetizations of L and R term in als the planar structure is augmented by a set of current-carrying lines known from MRAM devices. [1] We discuss two possible modes of operation for this system. In the rst mode, the magnetization of L contact is perturbed, and its dynamics is driving a current in the R contact. This leads to the possibility of an all-electrical measurement of m agnetization reversal. In the second mode, the L magnetization represents a bit of memory, and the rotation of the R contact triggers a transient current, the magnitude of which is related to the relative alignment of L and M magnetizations.

The spin accumulation in the channel and its connection to the alignment of the contacts is crucial for understanding of the system's operation. The current passing between L and M electrodes is spin polarized due to the spin selectivity of thin Schottky barriers. [8, 9] The

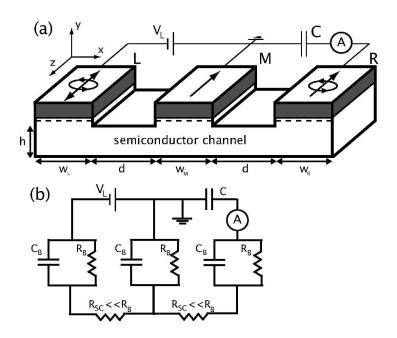


FIG. 1: (a) Proposed system: the structure is grown on top of an insulating layer as a mesa. The magnetization directions are manipulated by wire strips (not shown) above and below the structure, like in MRAM cell. Current in the R contact is measured. In the calculations we use h=100 nm,  $w_L=w_M=w_R=400 \text{ nm}$ , d=200 nm and length in the z direction of 2 m. (b) The equivalent circuit diagram (spin-independent):  $C_B$  is barrier capacitance,  $R_B$  and  $R_{SC}$  are barrier and sem iconductor channel resistances, respectively. See the text for description of spin e ects.

am ount of spin accumulation (proportional to the spin splitting of electrochem ical potential dened below) in the sem iconductor depends on whether the L and M magnetizations are parallel (P) or anti-parallel (AP). In the P case, the excess injected spin population is easily drained from the channel, while in the AP case opposite spins are more e-ciently injected and extracted, leading to much larger spin accumulation. Using the notations in Fig. 1 the e-ective length of the active channel covered by the L and M term inals is  $1 \text{ d} + w_L + w_M$ . Beneath the R contact, we then have from Ref. 7 approximately  $_{\text{AP}} = _{\text{P}} (2L_{\text{SC}} = 1)^2$ . In the steady state, when no current is owing through R electrode, its electrochemical potential R (having spin splitting negligible compared to the splittings in the sem iconductor) depends on the spin accumulation beneath the contact, and on the direction of R magnetization relative to the reference direction of M magnet. The boundary condition [18, 19] connecting the electrochemical potential R (spin s= ) with the spin current js at the interface is ejs=G\_s(R), where G\_s is the barrier conductance for spin s. U sing this, the requirement

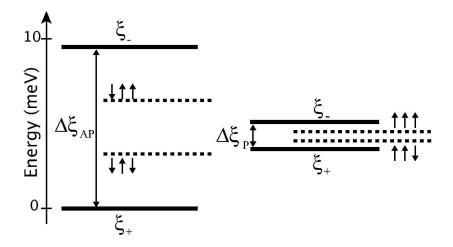


FIG. 2: Spin accumulation under the R contact and voltage inside it for antiparallel (AP) or parallel (P) magnetization alignment of the L and M term in als. Solid lines are the spin-dependent electrochem ical potentials in the sem iconductor channel beneath the R contact. D ashed lines are the values of electrochem ical potential  $_{\rm R}$  in the R contact in the steady state, depending on the R direction, with arrows denoting the alignment of three magnets.

of zero net current gives

$$R = + \frac{G_{+}^{R} - G_{-}^{R}}{G_{+}^{R} + G_{-}^{R}} \frac{1}{2} ; \qquad (1)$$

where is the mean potential beneath R contact and is its spin splitting. When the L magnetization is rotated, changes, and when R magnet is switched,  $G_+^R$  and  $G_-^R$  trade places. In both cases, perturbation of one of the magnets leads to transient currents charging the capacitor. The values of steady-state R for different contact alignments are illustrated in Fig. 2 (dashed lines) with respect to the spin-resolved potentials in the channel beneath the R contact (solid lines). The perturbation of either R or L magnet changes R between these values. If the RC time constant of the entire circuit is shorter than a time-scale of magnetization dynamics, it is possible to trace out the magnetization dynamics by electrical means. If is unchanged (when only R is rotated), then the signal is expected to differ strongly in magnitude depending of the L/M alignment, due to the ratio of spin splittings mentioned above. This leads to a dynamical readout of the L magnetization direction by rotating the R magnet.

In contrast to previous treatments of time-dependent spin di usion [16, 17], we treat the transport in a planar sem iconductor by a method [18], in which the elect of traversing under nite width of the metal contacts and barrier capacitance are taken into account. The

electrochem ical potential is de ned [19] for spin s= in a non-degenerate sem iconductor as  $_s=2k_B\,T\,n_s=n_0$  e , where  $n_s$  is the non-equilibrium part of the spin density,  $n_0$  is the free electron concentration, and is the electrostatic potential. The spin selectivity of the barrier is described by the nesse  $F=(G_+-G_-)=G_-$  with  $G=G_++G_-$ . We introduce two dimensionless parameters to quantify, respectively, the total conductance of the barrier and its spin selectivity:  $=2L_{sc}^2G=(h)$  and =F, where h is the thickness of the conducting channel (see Fig. 1) and is the conductivity of the sem iconductor. The y-average of  $_s$  over the thickness of the channel, denoted by  $_s$  is used in the transport equations. [18] In terms of the splitting =+ and the mean =(++)=2 we have the spin diffusion equation

$$\frac{\theta}{\theta t} = D \frac{\theta^2}{\theta x^2} + \frac{i(t)}{s} (i) \qquad \frac{i}{2s} \qquad \frac{i}{s}$$
 (2)

where  $_{\rm i}$  is the electrochem ical potential in the i<sup>th</sup> ferrom agnet and  $_{\rm S}$  is the sem iconductor spin relaxation time. To complete the equations for and , we use the excellent approximation of quasi-neutrality in the channel at all times ( $n_+ + n_- = 0$ ). In steady state, the quasi-neutrality condition follows from the smallness of the ratio of Ferm i screening length to spin dirusion length. [20] In the time-dependent case, deviations form neutrality are screened out on the scale of the dielectric relaxation time  $_{\rm d} = _{\rm 0} =$ , which is 100 fs for the sem iconductor channel in our case [21]. For the dynamics on longer time-scales (at least tens of picoseconds), we can assume that at every time-step the quasi-neutrality is preserved. Consequently, is proportional to and it satis es the Laplace equation with von N eum ann boundary conditions related to currents at the boundaries of the channel, which in the time-dependent case include also a displacement current connected with charging of the barrier capacitance  $C_{\rm B}$ . The equation for in the channel is then:

$$\frac{\theta^2}{\theta x^2} = \frac{i}{2L_{SC}^2} \left( i \right) + \frac{i(t)}{4L_{SC}^2} \qquad \frac{c_B}{h} \frac{\theta}{\theta t} \left( i \right) : \tag{3}$$

where  $c_B$  is the barrier capacitance per unit area, and the right hand side of Eq. (3) is non-zero only under the contacts.

The barrier conductances  $G_s$  refer to the two spin directions s= along the quantization axis parallel to the M m agnetization. During the magnetization dynamics, we employ the barrier nesse F (t) value proportional to the projection of the magnetization on the quantization axis, while keeping total G constant. Thus, we neglect the e ects of m ixing conductance", [22] which are expected to be small for tunneling barriers. The magnetization

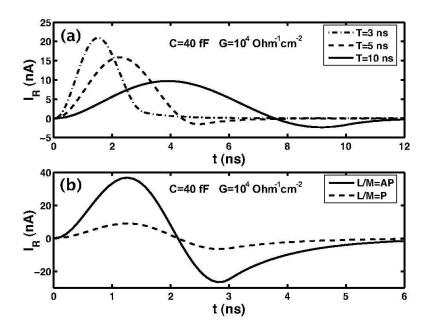


FIG. 3: (a) R current signal for reversal of L m agnetization occurring on time-scale of 3, 5 and 10 ns starting from AP alignment of L relative to M m agnet. (b) R current signal for 2 rotation of R m agnet for P and AP alignments of L and M m agnets. The period of rotation is 3 ns.

tion dynam ics of  $i^{th}$  contact translates into time-dependence of  $_{i}$ , driving the spin division in Eq. (2) and electric potential in the channel in Eq. (3). From  $_{s}$  we calculate the current  $I_{R}$  owing into the right contact and charging the capacitor C, and consequently the electrochem ical potential of the R term inal  $_{R}$  =  $_{e}V_{R}$  changes according to  $_{e}V_{R}$  =dt=  $_{e}I_{R}$  = $_{e}C$ .

For the electrical tracing of L m agnetization dynam ics, both M and R m agnets should be pinned in the same direction. In the case of the dynam ical readout of L/M alignment, we need to write separately the memory bit (direction of L m agnet) and read by rotating the R magnet. A proper choice of dierent coercivities of two magnets and magnetic eld pulses should allow for separate addressing. The half-selection (unintentional perturbation of magnetization) of L when rotating R should be diminished, in order not to mix the signal from the L dynamics with the readout of L alignment.

For the calculations, we use the param eters of GaAs at room temperature:  $_{\rm s}$ = 80 ps, doping n=  $10^{16}$  cm  $^{3}$ , mobility = 5000 cm  $^{2}$ /V swith corresponding discion constant D = kT=e. The dimensions of the system are given in Fig. 1. Beneath the barriers we assume a heavily doped pro le [8] so that the Schottky barriers are thin (< 10 nm), enabling spin injection [23]. We employ the experimentally veried [9] spin selectivity  $G_{+}$ = $G_{-}$ = 2 and take the barrier

conductance to be  $G=10^4$   $^1$  cm  $^2$ . For such barriers of 1 m  $^2$  area and 10 nm thickness,  $R_B=10~k$  and  $C_B=10~fF$ . The external capacitance is taken as C=40~fF, and the resulting RC time is about 1 ns. The applied voltage  $V_L$  is 0:1 V, and the ratio of forward to reverse biased G is set to 2.

In Fig. 3a we present the calculated  $I_R$  induced by reversal of the L magnet from AP to P alignment relative to M. In Fig. 3b the transient  $I_R$  for the rotation of R occurring in 3 ns is shown. While the average current is zero, the average power of the current pulse is much higher for the L/M = AP than for P. Two signals of such clearly dierent magnitude can be easily distinguished, provided that the stronger signal is above the noise level (dominated by Johnson noise in our system). In Fig. 3b the power of AP pulse is slightly above the noise power in 0.3 GHz bandwidth.

In sum mary, we have proposed a metal-sem iconductor system in which the dynamics of one of magnets can be sensed electrically. This opens up a possibility for electrical detection of magnetization switching dynamics in buried structures, inaccessible to magneto-optical techniques. We have also discussed a possibility for dynamical read-out of magnetization direction of one of the term inals, which can be used for magnetic memory purposes. Our ideas are supported by calculations of time-dependent spin di usion, taking into account realistic geometry of the structure. Further developments of including a scheme of all-magnetic logic gate will be presented in upcoming publications.

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<sup>[1]</sup> S. Tehrani, B. Engel, J.M. Slaughter, E. Chen, M. DeHerrera, M. Durlam, P. Naji, R. Whig, J. Janesky, J. Calder, IEEE Trans. Magn. 36, 2752 (2000).

<sup>[2]</sup> S.D atta and B.D as, Appl. Phys. Lett 56, 665 (1990).

<sup>[3]</sup> J. Schliem ann, J. C. Eques and D. Loss, Phys. Rev. Lett. 90, 146801 (2003).

<sup>[4]</sup> C.Ciuti, J.P.McGuire, and L.J.Sham, Appl.Phys.Lett 81, 4781 (2002).

<sup>[5]</sup> J. Fabian and I. Zutic, Phys. Rev. B 69, 115314 (2004).

<sup>[6]</sup> M.E.Flatte, Z.G.Yu, E.Johnston-Halperin and D.D.Awschalom, Appl. Phys. Lett 82, 4740 (2003).

- [7] H.Dery, L.Cywinski, and L.J.Sham, Phys.Rev.B 73 161307 (R) (2006).
- [8] A.T. Hanbicki, B.T. Jonker, G. Itskos, G. Kioseoglou, and A. Petrou, Appl. Phys. Lett. 80, 1240 (2002).
- [9] A.T. Hanbicki, O.M. J. van't Erve, R. Magno, G. Kioseoglou, C. H. Li, B. T. Jonker, G. Itskos, R. Mallory, M. Yasar, and A. Petrou, Appl. Phys. Lett. 82, 4092 (2003).
- [10] C. Adelmann, X. Lou, J. Strand, C. J. Palm strom, and P. A. Crowell, Phys. Rev. B 71, 121301 (R) (2005).
- [11] S.A. Crooker, M. Furis, X. Lou, C. Adelmann, D. L. Smith, C. J. Palmstrom, and P. A. Crowell, Science 309, 2191 (2005).
- [12] M. Johnson, Science 260, 320 (1993).
- [13] F.J. Jedem a, A.T. Filip, and B.J. van Wees, Nature 410, 345 (2001).
- [14] Y. Ji, A. Ho man, J.E. Pearson, and S.D. Bader, Appl. Phys. Lett. 88, 052509 (2006).
- [15] J.Nogues and I.K. Schuller, J.Magn.Magn.Mat. 192, 203 (1999).
- [16] E.J. Rashba, Appl. Phys. Lett. 80, 2329 (2002).
- [17] S. Zhang and P.M. Levy, Phys. Rev. B 65, 052409 (2002).
- [18] H.Dery, L.Cywinski, and L.J.Sham, Phys.Rev.B 73 041306(R) (2006).
- [19] Z.G.Yu and M.E.Flatte, Phys. Rev. B 66, 235302 (2002).
- [20] S.Hersh eld and H.L.Zhao, Phys. Rev. B 56, 3296 (1997).
- [21] R.A.Smith, Semiconductors (Cambridge University Press, Cambridge, England, 1978).
- [22] A.Brataas.Y.V.Nazarov and G.E.W.Bauer, Phys.Rev.Lett.84, 2481 (2000); Eur.Phys. J.B 22, 99 (2001).
- [23] E.I.Rashba, Phys. Rev. B 62, R16267 (2000).